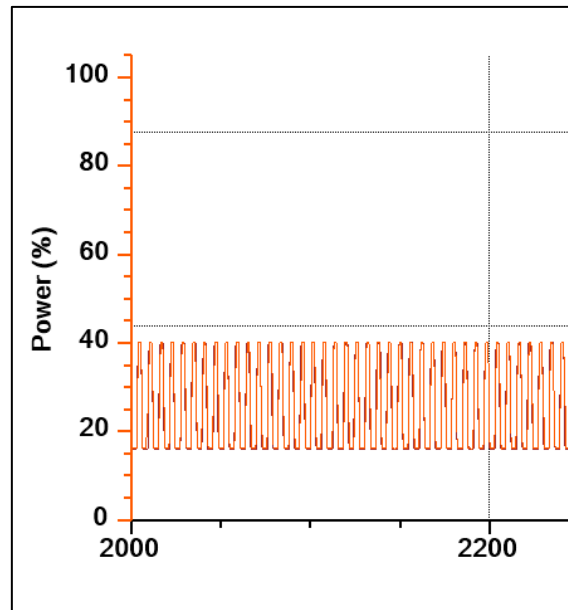


Annealsys join C2MI ecosystem

Montpellier, France, May 13, 2021

Annealsys is happy to join **C2MI** ecosystem as an industrial partner. Annealsys RTP furnaces are used by many companies and laboratories worldwide for the development and the production of MEMS and sensors. The pulse annealing capabilities of our RTP systems allow the development of new processes for annealing layers on top of thermally sensitive substrates. This technology can even be used for the annealing of layers on top of polymers using the cold wall chamber to keep the substrate at low temperature.



About C2MI

The C2MI is an international reference in the fields of advanced packaging and microsystems. It is the fundamental link between applied research and the rapid commercialization of microelectronic products.

More information about C2MI: <https://www.c2mi.ca/en/>

About Annealsys:

Founded in 2004, Annealsys with more than 300 machines installed worldwide, is a leading manufacturer of Rapid Thermal Processing (RTP) and Direct Liquid Injection Deposition systems. We are supplying number of companies with production tools for the manufacturing of MEMS, sensors, optoelectronics, telecommunication, power and discrete devices. Many famous laboratories worldwide are using our machines for the development of future semiconductor, photovoltaic and nanotechnologies components.

Our philosophy involves building up a long-term relationship with our customers, providing high reliability and high quality tools, insuring low cost of ownership and offering outstanding customer support and service. To achieve this, we have created a worldwide network with trained engineers for sales and service.

For more information visit Annealsys web site at www.annealsys.com